

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of:

Toshihiko OHASHI et al.

Application No.: 10/541,776

Confirmation No.: 1474

Filed: July 08, 2005

Art Unit: 1794

For: SILICA-CONTAINING LAMINATED
STRUCTURE, AND COATING
COMPOSITION FOR USE IN FORMING A
POROUS SILICA LAYER

Examiner: V. CHANG

DO NOT ENTER: /V.C./

AMENDMENT UNDER 37 C.F.R. § 1.116

MS AF

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the Office Action dated July 30, 2010, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

Amendments to the Claims begin on page 2.

Remarks begin on page 8.

Attachments: Exhibits 1-3